Digest of Tech. Papers The 6th Conf. on Solid State Devices, Tokyo, Sep. 1974 A4-3 Control of Two-Dimensional High Field Domain in Gunn Effect Functional Devices

T.Nakamura, S.Hasuo, G.Goto, K.Kazetani, H.Ishiwari, H.Suzuki and T.Isobe Fujitsu Laboratories Ltd., 1015 Kamikodanaka, Nakahara-ku, Kawasaki

Introduction It has been considered that a transverse extension velocity of a high field domain is much higher than a domain propagation velocity, and a high speed carry generator utilizing the transverse extension has been proposed. It has been demonstrated with the aid of a computer simulation that a comb-shaped Gunn effect device is promising as a carry generator to be operated in a full adder or subtracter circuit. It is a purpose of this paper to confirm a possibility to control the two-dimensional extension of a high field domain and to approach device applications.

Figure 1 shows an Comb-shaped carry generator N-bit full adder circuit composed of exclusive-OR gates and a comb-shaped carry generator utilizing a transverse extension of a high field domain. This carry generator consists of N-bits of tooth-like Gunn devices bridged at their cathodes. Each stage of the comb-shaped device is provided with a Schottky gate to control a high field domain and ohmic gate electrodes are set opposite to the common cathode in each bridge section. It is the most important feature for this carry generator to control the twodimensional extension of the high field domain with the ohmic gates.

<u>Design of optimum gate size</u> In order to decide the width of the bridge section between two bits and

to decide the length from cathode to ohmic gate, we should estimate a transverse extension velocity of an immature domain. The transverse extension of a mature high field domain has been discussed by Shoji, and the extension velocity has been estimated to be in order of 108 cm/sec. However, it is not obvious that the extension velocity of an immature domain in a stage of a nucleation is so fast as that of a mature high field domain, so that it is necessary to discuss a twodimensional domain intiation and to introduce the transverse extension velocity of the immature domain. We estimated them in a small signal approximation and got results that the transverse extension velocity is 1.3×10° cm/sec for the doping density $n_e = 10^6 \text{ cm}^3$, and that is $4.2 \times 10^7 \text{ cm/sec}$ for $n_e = 10^{15} \text{ cm}^3$. On the other hand, since the field dependence of the diffusion coefficient of electrons is negative in the field region above the threshold of the negative differential mobility, the drift velocity of the immature domain toward the bias field is 1.7×108 cm/sec for $n_s=10^{16}$ cm⁻³, and that is 3.5×10^{7} cm/sec for $n_s=10^{15}$ cm⁻³. Therefore, the length of the bridge section should be larger than a marginal distance for the immature domain to travel in a domain formation time. We estimate this marginal distance to be $3 \mu m$ for $n_o = 10^{16} cm^3$, and $10 \mu m$ for $n_o = 10^{15} cm^3$. The width of the bridge section should be comparable with or less than the bridge length because of the fact that the transverse extension velocity is not so fast compared with the longitudinal propagation velocity in the stage of the domain formation.

<u>Computer simulations</u> We have simulated a 2-bit comb-shaped carry generator to confirm its logical operation and the two-dimensional domain controllability.



Fig.1 An N-bit full adder composed of a comb-shaped carry generator and exclusive-OR (comparator) using Gunn effect Figure 2 shows time variations of field distributions in the device. The width and the length of the bridge section are set equal to 10 µm and 8 µm respectively, the length from cathode to anode is 24 µm, and the doping density in the active region is 10^{15} cm^3 . When the applied voltage for the bridge section is 3.0 volts, the electric field is high enough to sustain the transverse extension of the domain nucleated in the first stage and a new domain is formed in the second stage. On the other hand, when that is 2.5 volts, the domain does not extend toward the bridge section. It is confirmed in these simulations that the domain can be controlled to extend by changing the electric field in the bridge section. When the device size is decreased into a half dimensions, however, the domain could not be controlled to extend toward the higher stage. This is an expected result from the small signal calculations.

<u>Experiments</u> We fabricated 2-bit combshaped planar Gunn devices and confirmed the logical operation as a carry generator. Typical dimensions of the device are as follows; the length from cathode to anode is 100 μ m, the width and the length of the bridge section are 50 μ m and 25 μ m respectively. The doping density of the active region is $7 \times 10^{15} \text{ cm}^3$. The first stage is provided with a Schottky gate to nucleate a domain.

The current waveforms for each stage are shown in Fig.3. When the gate voltage was about 9 volts against the cathode,

the domain nucleated in the first stage did not extend toward the second stage as shown in right two traces in Fig.3. On the other hand, when that was increased by 0.5 volts, the domain extended toward the second stage and a new domain was formed. The delay time of the domain formation between two stages was less than 50 psec. We confirmed the logical operation in the device stated above, but in a device with other gate size much different from the above dimensions, the domain could not be controlled. The domain could not be suppressed to extend in a device with a longer gate length than 50 μ m, and it could not be extended in a device with a shorter gate length than 10 μ m.

We also fabricated a 4-bit comb-shaped carry generator and confirmed the logical operation. The delay time of the domain formation between the first stage and the fourth stage was about 100 psec.

<u>Conclusion</u> Two-dimensional domain extension can be controlled by changing the electric field at the position where the domain is to extend. These controllabilities are confirmed both with computer simulations and experiments. But it must be noted that the design of the bridge section of the carry generator is the most important factor to control the domain extension.



Fig.2 Computer simulated electric field distributions in 2-bit carry generator. Left three figures are for gate 'ON', and right three are for gate 'OFF'.





GATE - OFF

Fig.3 Current waveforms for each stage in 2-bit carry generator. Upper two traces are those for the first stage when the ohmic gate is 'ON' and 'OFF'. Lower two traces are for the second one.